



GEH RESEARCH

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To

Pooja Sharma

Indira College of Engineering and Management

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Ongoing Project – Status:

Date: 28/03/2022

File No.: 4645/GEH-Research/policy-1/1021-24/2022/W-283-5

Project Title: Method for Academic Achievement using Deep Learning

Scheme: Core Reserch Grant/ Extramural Reserch

Area: Science and Engineering

Technology transferred: Yes (GEH Research)

Total Cost: 9, 70,500.00

Project Status: 59% Completed

Started date: 24/12/2021

End Date: 02/11/2024

Funding Source: Govt. of Germany, USA, and India, Donate to Other Society, Company Products Benefit.

Name of the Industry /Organization: GEH Research.

Address: GEH RESEARCH, G-12, LAVELLE ROAD, BENGALURU, KARNATAKA-560001, INDIA

Name of Competent Authority and Designation: Dr. R. Singh (Director)

Industry Web Address: www: gehresearch.com

Brief Details on Industry: (Product: 1: Innovative Idea Convert into a patent, 2: Patent idea Convert into a Prototype, 3: Granted Patent Products Develop. 4: Fund Provide Any Patented Idea Convert into a Products. **Turnover:** 1089.00 Cr. **Expertise:** Research and Innovation.

Accomplishment of Industry Partner:

1: Training providers. 2: Companies that provide testing services, both on and off site. 3: Real –time Patent Products Develop and design Help.4: Companies may employee both Practitioners and Industry Partners.

Prof. (Dr). R. Singh

**(Reg. Patent Attorney, Patent Lawyer)
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AAE-4645-GEH RESEARCH

